Charge Transport in Split-gated Point Contact based on MoS₂/WSe₂ Heterostructure

Nhat Anh Nguyen Phan¹, Inayat Uddin¹, Hai Yen Le Thi², Nobuyuki Aoki³, Kenji Watanabe⁴, Takashi Taniguchi⁵, and Gil-Ho Kim^{1,2}

¹Department of Electrical and Computer Engineering, Sungkyunkwan University (SKKU), Suwon 16419, Republic of Korea

²Sungkyunkwan Advanced Institute of Nanotechnology (SAINT), Sungkyunkwan University (SKKU), Suwon 16419, Republic of Korea

³Department of Materials Science, Chiba University, Chiba 263-8522, Japan

⁴Research Center for Functional Materials, National Institute for Materials Science, 1-1 Namiki, Tsukuba 305-

0044, Japan

⁵International Center for Material Nano-Architectonics, National Institute for Materials Science, 1-1 Namiki, Tsukuba 305-0044, Japan

ghkim@skku.edu

As advancements in quantum phenomena coincide with the ongoing miniaturization of nano-semiconductor transistors, the exploration of novel quantum structures beyond conventional types becomes essential [1]. This study delves into the investigation of electrostatically defined nanoscale devices within 2D semiconductor heterostructures, particularly focusing on van der Waals heterostructures, which offer notable advantages such as large-scale uniformity and flexibility [2,3]. The research presented here scrutinizes the charge transport characteristics within a split-gated point contact device of a MoS₂/WSe₂ heterostructure. It elucidates the step-like behavior observed under the influence of split-gate and middle-gate control, while also examining the confinement transport mechanisms governed by split-gate and back-gate configurations. Through meticulous electrostatic manipulation, the interplay between quantum confinement and gate control is explored, providing valuable insights into the engineering of nanoelectronic devices. The observed step-like current profile underscores the intricate relationship between quantum effects and gate voltage modulation, thereby shedding light on the underlying physics governing charge transport in two-dimensional semiconductor heterostructures. By systematically varying gate voltages and temperatures, this study reveals the temperature-dependent nature of charge scattering mechanisms and the pivotal role of gate potentials in manipulating carrier concentration and transport pathways. These findings significantly contribute to a deeper understanding of electrostatic effects in 2D transition metal dichalcogenide heterostructures, thus paving the way for the development of advanced electronic devices with tailored confinement for enhanced functionalities [4].

References

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Fig.1. a) Schematic of the WSe_2/MoS_2 device. b) Confinement transport under split-gate and back-gate control. c) Step-like currents at 77 K for a series of V_{SG} and V_{MG} .